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## Revealing the activity and selectivity of ppm level copper in gas diffusion electrodes towards CO and CO<sub>2</sub> electroreduction†

Xiang Lyu,<sup>ib ab</sup> Jianlin Li,<sup>ib b</sup> Tianyu Zhang,<sup>a</sup> Zhengyuan Li,<sup>a</sup> In-hui Hwang,<sup>c</sup> Chengjun Sun,<sup>c</sup> Charl J. Jafta,<sup>ib b</sup> Jun Yang,<sup>b</sup> Todd J. Toops,<sup>d</sup> David A. Cullen,<sup>ib e</sup> Alexey Serov<sup>\*b</sup> and Jingjie Wu<sup>ib \*a</sup>

Cu is a unique metal that catalyzes carbon monoxide/carbon dioxide (CO/CO<sub>2</sub>) to form high-order hydrocarbons and oxygenates through the CO/CO<sub>2</sub> reduction reaction (CO/CO<sub>2</sub>RR) at decent selectivity and productivity. While this has been shown, the limits of the system are still unknown, *i.e.*, the minimum amount of Cu needed for the CO/CO<sub>2</sub>RR, and the maximum activity that trace amounts of Cu can achieve. Here, we have investigated the activity and selectivity of trace Cu with atomic dispersion over a range of loadings below 2 μg cm<sup>-2</sup> and have quantified the mass activity/turnover frequency (TOF) of trace Cu catalysts. A Cu loading of at least 0.042 μg cm<sup>-2</sup> initiates the CORR activity with 30% faradaic efficiency (FE) at a partial current density of 102 mA cm<sup>-2</sup> forming predominantly CH<sub>4</sub>. The selectivity moves to C<sub>2</sub>-based products (CH<sub>3</sub>COO<sup>-</sup>, C<sub>2</sub>H<sub>4</sub>, and CH<sub>3</sub>CH<sub>2</sub>OH) with 70% FE as the Cu loading increases to 0.333 μg cm<sup>-2</sup>, and increasing the Cu loading to 0.812 μg cm<sup>-2</sup> results in a 78% FE to C<sub>2</sub> with CH<sub>3</sub>COO<sup>-</sup> accounting for 42% of this. The highest mass activity for CH<sub>4</sub> reaches 2435 A mg<sup>-1</sup> of Cu, corresponding to a TOF of 267 s<sup>-1</sup>, while C<sub>2</sub> activity reaches 584 A mg<sup>-1</sup> of Cu, leading to a TOF of 145 s<sup>-1</sup>. Both TOFs are several orders of magnitude higher than the reported values. Different from the CORR, the CO<sub>2</sub>RR demands a higher Cu loading and primarily generates C<sub>1</sub> (*e.g.*, CO and CH<sub>4</sub>). Metal impurities can be extended to others that are active towards the CO<sub>2</sub>RR, such as Zn for CO<sub>2</sub>-to-CO conversion. Thus, we suggest that the effect of trace metal impurities must be quantified when developing carbon-based metal-free and coordinated single-atom catalysts for the CO/CO<sub>2</sub>RR in order to avoid overestimating their activity.

### Broader context

Carbon dioxide (CO<sub>2</sub>) removal and utilization have become an essential feature of climate mitigation. The electrochemical CO<sub>2</sub> reduction reaction (CO<sub>2</sub>RR) to form valuable chemicals and fuels utilizing renewable energy is a promising strategy contributing to the carbon-net-zero goal. A catalyst with high activity and selectivity is critical to enabling the large-scale application of the CO<sub>2</sub>RR. Cu-based catalysts are uniquely known hydrocarbon- and oxygenate-selective metal catalysts. Meanwhile, metal-free carbon-based and metal-nitrogen-carbon (M-N-C with metals of Fe, Ni, and Co) single-atom catalysts have been developed as alternatives to conventional metal catalysts for the CO/CO<sub>2</sub> reduction reaction (CO/CO<sub>2</sub>RR). Since trace Cu on carbon-based supports was reported to show activity towards the CO<sub>2</sub>RR, the performance overestimation of metal-free and M-N-C catalysts during the CO/CO<sub>2</sub>RR is a concern. Currently, two questions remain elusive: what is the lowest limit Cu loading to show activity for the CO/CO<sub>2</sub>RR, and how high is the activity that trace amounts of Cu can achieve? Both questions are critical to scientifically evaluate the intrinsic performance of the catalysts during the CO/CO<sub>2</sub>RR. In this work, we answered both questions by revealing the activity and selectivity of ppm level copper in gas diffusion electrodes towards the CO/CO<sub>2</sub>RR.

## Introduction

The electrochemical CO<sub>2</sub> reduction reaction (CO<sub>2</sub>RR) to form valuable chemicals and fuels utilizing renewable energy has attracted remarkable attention, as it is beneficial in producing value-added products while simultaneously consuming CO<sub>2</sub> under mild operating conditions.<sup>1-4</sup> Nevertheless, the practical cost is still high for large-scale applications partly because of the low selectivity, efficiency, and durability of existing electrocatalysts.<sup>5-7</sup> The state-of-the-art electrocatalysts for the CO<sub>2</sub>RR are metallic.<sup>8-11</sup> Ag, Au, and Zn mainly convert CO<sub>2</sub> to carbon monoxide (CO),<sup>12-15</sup> while Sn and Bi are selective to formate (HCOO<sup>-</sup>) *via* a two-electron reduction process in the CO<sub>2</sub>RR.<sup>16-18</sup> Cu stands out as the only known metal catalyst capable of generating high-order products such as C<sub>1</sub>-C<sub>2</sub> hydrocarbons (*e.g.*, CH<sub>4</sub> and C<sub>2</sub>H<sub>4</sub>) and C<sub>2</sub> oxygenates (*e.g.*, CH<sub>3</sub>CH<sub>2</sub>OH, CH<sub>3</sub>COOH, and

<sup>a</sup> Department of Chemical and Environmental Engineering, University of Cincinnati, Cincinnati, OH, USA. E-mail: jingjie.wu@uc.edu

<sup>b</sup> Electrification and Energy Infrastructures Division, Oak Ridge National Laboratory, Oak Ridge, TN 37831, USA. E-mail: serova@ornl.gov

<sup>c</sup> X-Ray Science Division, Argonne National Laboratory, IL 60439, USA

<sup>d</sup> Buildings and Transportation Science Division, Oak Ridge National Laboratory, Oak Ridge, TN 37831, USA

<sup>e</sup> Center for Nanophase Materials Sciences, Oak Ridge National Laboratory, Oak Ridge, Tennessee, 37831, USA

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C<sub>3</sub>H<sub>7</sub>OH<sub>2</sub>) beyond the 2e<sup>-</sup> reduction route.<sup>19–23</sup> Moreover, Cu is also the unique metal that catalyzes the electrochemical CO reduction reaction (CORR), a critical intermediate reaction in the CO<sub>2</sub>RR, to form a similar distribution of C<sub>2+</sub> hydrocarbons and oxygenates.<sup>24,25</sup>

A trace level of Cu nanoparticles (*e.g.*, 119 ppm) in graphene oxide loaded on a glass carbon substrate exhibited electrochemical activity towards the CO<sub>2</sub>RR in an H-cell.<sup>26</sup> The carbon products were only C<sub>1</sub> (CO, CH<sub>4</sub>, and HCOOH) with a total faradaic efficiency (FE) of about 15% and a total current density of around 5 mA cm<sup>-2</sup> at -1.3 V *versus* reversible hydrogen electrode (*vs.* RHE throughout the text). Fu *et al.* prepared atomically dispersed Cu atoms with a low loading of 69 μg cm<sup>-2</sup> on nitrogen-rich porous carbon supports and then loaded them onto a carbon paper substrate as gas diffusion electrodes (GDEs).<sup>27</sup> They reported ~60% FE to C<sub>2</sub> products in the CORR under a total current density of 75 mA cm<sup>-2</sup> at -0.7 V, while CH<sub>4</sub> formation was negligible. Rong *et al.* synthesized atomically dispersed Cu atoms on a graphdiyne support loaded on a carbon paper substrate to make GDEs as well.<sup>28</sup> They observed that the major product of the CORR switched from C<sub>1</sub>/CH<sub>4</sub> (57.3% FE) to C<sub>2</sub> (80% FE) at -1 V as the atomically dispersed Cu loading increased from 7.5 to 226 μg cm<sup>-2</sup>. Those findings indicated that the content of trace Cu on carbon-based supports can substantially influence the electrochemical activity and selectivity in the CO/CO<sub>2</sub>RR. However, the maximum mass activity and turnover frequency (TOF) in the CO/CO<sub>2</sub>RR that can be achieved with trace Cu is still unknown. Moreover, understanding how decreasing the Cu loading impacts selectivity in the CO/CO<sub>2</sub>RR is also unknown.

An alternative approach under investigation is the use of metal-free carbon catalysts and metal–nitrogen–carbon (M–N–C with metals of Fe, Ni, and Co). Most carbon and M–N–C catalysts show predominant products of C<sub>1</sub> (*e.g.*, CO and CH<sub>4</sub>) in the CO/CO<sub>2</sub>RR.<sup>29–33</sup> For example, the graphitic-N doped graphene-like carbon catalyst was reported to convert CO<sub>2</sub> to CO with a 95% FE and partial current density of 9.07 mA cm<sup>-2</sup> at -0.72 V.<sup>31</sup> N-doped graphene quantum dots (NGQDs) with functionalized electron-donating groups (*e.g.*, -OH and -NH<sub>2</sub>) could catalyze CO<sub>2</sub> to CH<sub>4</sub> with both high selectivity (70% FE) and production rate (partial current density of 200 mA cm<sup>-2</sup>) at -0.85 V.<sup>32</sup> The single Zn atom supported on a microporous N-doped carbon catalyst was reported to catalyze CO<sub>2</sub> to CH<sub>4</sub> with an 85% FE and partial current density of 31.8 mA cm<sup>-2</sup> at -1.8 V (*vs.* Hg/HgCl<sub>2</sub>).<sup>34</sup> A few carbon catalysts were also reported to form C<sub>2</sub> products.<sup>35–37</sup> Rigorous evaluation of the activity to the CO/CO<sub>2</sub>RR of metal-free catalysts should consider the potential effect of trace metal impurities like Cu and Zn because metal impurities will be introduced from reactants/precursors during synthesis of the catalyst and from electrolytes during electrolysis.<sup>26,38–43</sup> Therefore, a systematic evaluation of trace metal loading-dependency on GDE was performed as it relates to the CO/CO<sub>2</sub>RR activity and selectivity.

Herein, to clearly reveal the effect of low levels (ppm) of Cu on the CO/CO<sub>2</sub>RR performance, trace amounts of Cu with a range of loadings was directly loaded onto carbon paper (CP, Sigracet 39BB gas diffusion layer) *via* a facile impregnation

method. This loading method does not use any additional carbon supports as reported in the literature and subsequently eliminates the effect of the carbon support on the performance. A significant activity towards the CORR is observed on trace Cu-loaded GDE when the loading is higher than 0.042 μg cm<sup>-2</sup> (4.9 ppm referred to the electrode mass). Cu loading down to 0.042 μg cm<sup>-2</sup> can lead to up to 50% FE of carbon products, with CH<sub>4</sub> as the major carbon product, at -0.76 V in the CORR. The primary product switches from C<sub>1</sub> to C<sub>2</sub> with a total 70% FE at -0.74 V when the Cu loading increases from 0.042 to 0.333 μg cm<sup>-2</sup>. The CO<sub>2</sub>RR requires a higher Cu content than the CORR to trigger the activity. Only predominant products of C<sub>1</sub> are observed at a Cu loading of 0.812 μg cm<sup>-2</sup>. The primary product switches from CO to CH<sub>4</sub> with the increase in overpotential. These findings indicate that a ppm level of Cu in the electrodes has a significant impact on the CO/CO<sub>2</sub>RR, especially on the CORR. In addition, this study proposes the importance of the design of Cu catalysts at the atomic scale to maximize the specific activity towards the CO/CO<sub>2</sub>RR.

## Results and discussion

### CORR activity over a trace Cu-loaded carbon paper.

The electrocatalytic activity and selectivity towards CO/CO<sub>2</sub> reduction were evaluated in a custom flow cell. The geometric area of the CP electrode is 2.8 cm<sup>2</sup> (1.67 cm × 1.67 cm), of which 1.0 cm<sup>2</sup> (1.0 cm × 1.0 cm) is the active area matching the dimensions of the flow field and the cathode compartment (more details in the Experimental methods of the ESI†). The CP electrodes containing a Cu loading of 0.812 μg cm<sup>-2</sup> (denoted as CP-Cu<sub>0.812</sub>) were first investigated for the CORR. CP-Cu<sub>0.812</sub> electrodes exhibit outstanding electrochemical activity to the CORR with the highest FE of carbon products reaching 83% at -0.64 V (Fig. 1a). The FE of C<sub>2</sub> (including CH<sub>3</sub>COO<sup>-</sup>, C<sub>2</sub>H<sub>4</sub>, and CH<sub>3</sub>CH<sub>2</sub>OH) products maintains high (>48%) in a wide potential window from -0.6 to -0.87 V (Fig. 1b), and the highest 78% FE of C<sub>2</sub> products is achieved at -0.64 V (Fig. 1b). In contrast, the FE of CH<sub>4</sub> only rises to a maximum of 19.1% as the potential is negatively swept to -0.86 V. The partial current densities for both C<sub>2</sub> and CH<sub>4</sub> (*j*<sub>C<sub>2</sub></sub> and *j*<sub>CH<sub>4</sub></sub>) monotonically increase as the potential is swept cathodically. The *j*<sub>C<sub>2</sub></sub> and *j*<sub>CH<sub>4</sub></sub> climb to 429 and 170 mA cm<sup>-2</sup>, respectively, at -0.86 V (Fig. 1c). The total current density of the carbon products with a Cu loading of 0.812 μg cm<sup>-2</sup> reaches 599 mA cm<sup>-2</sup> at -0.86 V, which is even higher than the Cu nanocube<sup>44</sup> and nanosheet<sup>45</sup> catalysts with loadings as high as 500 μg cm<sup>-2</sup> under similar operating conditions, indicating that the trace Cu on CP exhibits extraordinary electrochemical activity toward the CORR.

To systematically investigate the impact of trace Cu loadings on the CORR, we prepared CP electrodes with Cu loadings ranging from 0.016 to 1.53 μg cm<sup>-2</sup>, as shown in Table S1 (ESI†). Notably, the Cu loading in the as-received pristine CP is 0.016 μg cm<sup>-2</sup> (PCP-Cu<sub>0.016</sub>), and thus, the total Cu content in the prepared CP electrodes includes this Cu impurity in the PCP. The CORR performance of the CP electrodes with different





Fig. 1 (a) Product distribution during the CORR as a function of the applied potential on the CP-Cu<sub>0.812</sub> electrode. (b) FEs of C<sub>2</sub> and CH<sub>4</sub>. (c) The partial current density of C<sub>2</sub> and CH<sub>4</sub>. The error bars represent the standard deviation from the measurements of three independent electrodes.

Cu contents is shown in Fig. 2 and Fig. S2 (ESI<sup>†</sup>). A significant effect on the CORR is observed when the Cu loading exceeds 0.042 μg cm<sup>-2</sup> Cu (4.9 ppm Cu in the total electrode), and 50% FE of carbon products with the predominant carbon product of CH<sub>4</sub> is obtained at this Cu level. The peak FE of 39% for CH<sub>4</sub> is reached with CP-Cu<sub>0.070</sub> electrodes. The primary product switches to C<sub>2</sub> when the Cu loading further increases to 0.333 μg cm<sup>-2</sup>, indicating

that the C-C coupling reaction is accelerated with the existence of more Cu active sites. The highest C<sub>2</sub> FE of 78% is achieved at -0.64 V with a Cu loading of 0.812 μg cm<sup>-2</sup>. The current density of C<sub>2</sub> exhibits a positive correlation with the Cu loading, while the current density of CH<sub>4</sub> remains in a similar range with other Cu loadings.

The mass activity for C<sub>2</sub> reaches 584 A mg<sup>-1</sup> of Cu with a FE of 57% at -0.86 V for the CP-Cu<sub>0.333</sub> electrodes, which is 2–5

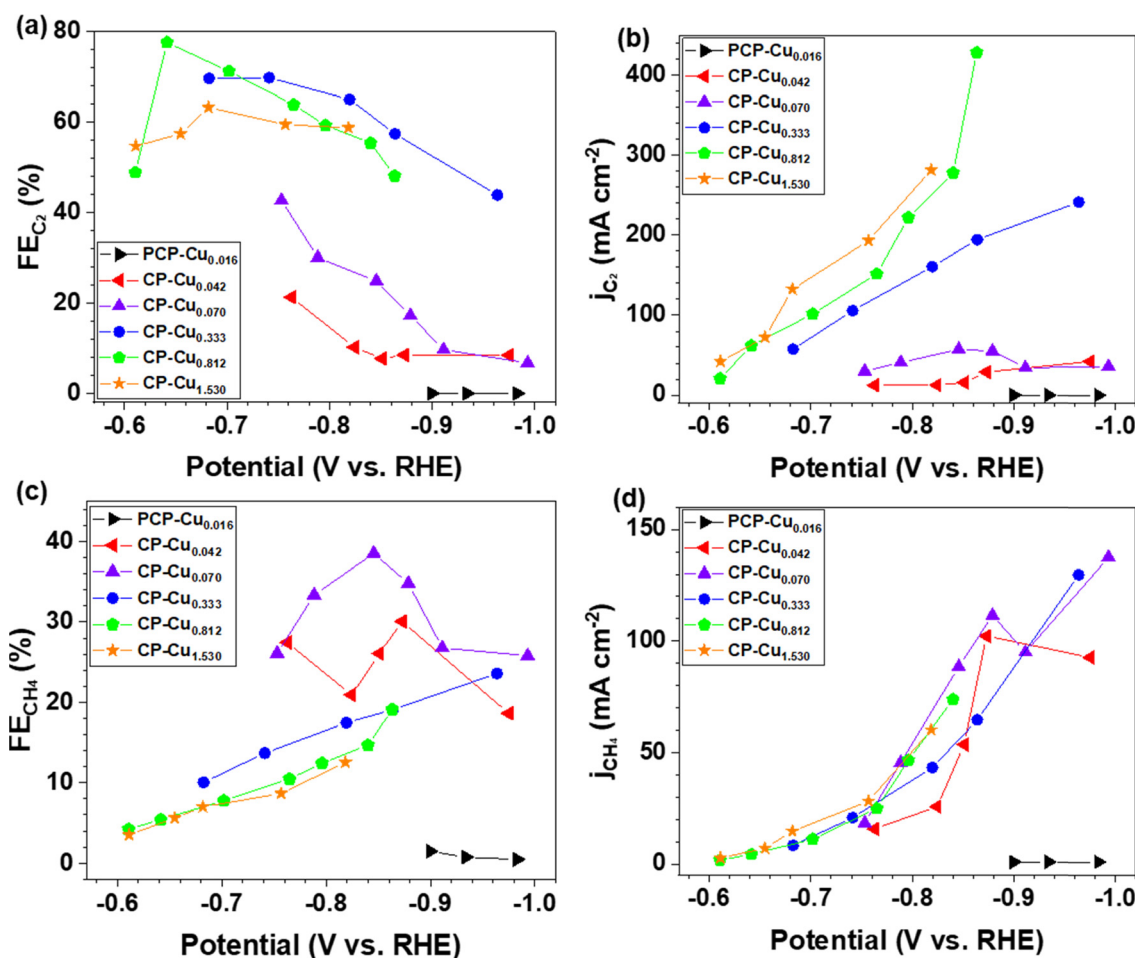


Fig. 2 (a) The partial current density and (b) FE of C<sub>2</sub> during the CORR as a function of the applied potential using CP-Cu electrodes with various Cu loadings. (c) The partial current density and (d) FE of CH<sub>4</sub> as a function of the applied potential using CP-Cu electrodes with various Cu loadings.



orders of magnitude higher than those reported in the literature (Table S2, ESI†). The mass activity for  $\text{CH}_4$  rises to  $2435 \text{ A mg}^{-1}$  of Cu with a FE of 30.1% at  $-0.87 \text{ V}$  using the CP-Cu<sub>0.042</sub> electrodes, which is an increase of 4 orders of magnitude compared with similar Cu/C electrode reported values.<sup>12</sup> This is a clear indication that a trace level of Cu can be very active and should always be accounted for in the CORR experiments.

A control experiment was carried out to evaluate the effect of the CP treatment with the solvent mixture of DI water and IPA but without additional  $\text{CuCl}_2$  on the CORR. After exposure to the solution, the Cu loading declines from  $0.016$  to  $0.006 \mu\text{g cm}^{-2}$ , indicating the Cu contamination in the PCP can be partially dissolved in the solvent mixture. The electrochemical results of the CP-Cu<sub>0.006</sub> electrodes are shown in Fig. S3 (ESI†). Only trace  $\text{CH}_4$  is produced and  $\text{H}_2$  predominates, which is a similar performance to PCP-Cu<sub>0.016</sub>. Another control experiment was performed to investigate the effect of solvent on the Cu impregnation, where the highest concentration of  $5 \text{ mM}$  of  $\text{CuCl}_2$  in DI water was used. The performance of this control electrode for the CORR is displayed in Fig. S4 (ESI†). The HER exclusively occurs under current densities from  $107$  to  $321 \text{ mA cm}^{-2}$ , and only trace amounts of  $\text{CH}_4$  with a FE < 2.2% are detected. This finding suggests that the Cu ions in pure DI water could not be loaded onto the CP substrate, as the CP surface is highly hydrophobic. Fig. S5 (ESI†) shows contact angle measurements on CP with pure DI water and a mixture of DI water/IPA (v/v: 1/1). The contact angle decreases from  $169$  to  $42^\circ \text{C}$  when replacing the pure DI water with the solvent mixture.

The product distribution of the CORR as a function of the trace Cu loading is further plotted in Fig. 3. The FEs of each CORR product under different Cu loadings are compared at the current density of around  $130 \text{ mA cm}^{-2}$  (Fig. 3a). The peak FE of 33% for  $\text{CH}_4$  is achieved with  $0.070 \mu\text{g cm}^{-2}$  Cu loading. The  $\text{CH}_3\text{COO}^-$  is predominant with a peak FE of 41% at a Cu loading of  $0.333 \mu\text{g cm}^{-2}$ . The results indicate that the trace level of Cu is already very active towards the CORR to form

$\text{CH}_3\text{COO}^-$ . The FE ratio of  $\text{C}_1/\text{C}_2$  is 1.1 with the CP-Cu<sub>0.070</sub> electrode, and it drops to 0.11 with the CP-Cu<sub>0.812</sub> electrode, indicating the selectivity varies by 10 times after  $0.742 \mu\text{g cm}^{-2}$  Cu is added. Fig. 3b depicts the product distribution of the CORR at around  $330 \text{ mA cm}^{-2}$  as the trace Cu loading increases, and a similar trend is observed with  $130 \text{ mA cm}^{-2}$ . The notable difference is that the FE of  $\text{C}_2$  decreases while the FE of  $\text{C}_1$  increases slightly at a higher current density and overpotential, as the high overpotential prefers  $\text{CH}_4$  formation.<sup>46–48</sup>

### The performance of CO<sub>2</sub>RR with different Cu loadings in carbon paper

The electrochemical activity of trace Cu on CP was also evaluated for the CO<sub>2</sub>RR (Fig. S6, ESI†). The low (CP-Cu<sub>0.070</sub>) and high (CP-Cu<sub>0.812</sub>) Cu loading electrodes were chosen for the CO<sub>2</sub>RR since these electrodes exhibit the predominant selectivity towards  $\text{C}_1$  and  $\text{C}_2$  in the CORR, respectively. The highest FE of carbon products with the CP-Cu<sub>0.070</sub> electrode in the CO<sub>2</sub>RR is 62%, lower than in the CORR (83%), indicating that the CO<sub>2</sub>RR is less sensitive to trace Cu than the CORR. It is worth pointing out that trace Cu favors formation of  $\text{C}_1$  products in the CO<sub>2</sub>RR, which is different from  $\text{C}_2$  products being favored in the CORR. The predominant product is CO at low potentials, and it transitions to  $\text{CH}_4$  when the potential is swept more negatively for both CP-Cu<sub>0.070</sub> and CP-Cu<sub>0.812</sub> electrodes. The peak FE of CO is 26% appearing at  $-0.57 \text{ V}$  for the CP-Cu<sub>0.070</sub> electrode while the maximum FE of  $\text{CH}_4$  is 24% at  $-0.67 \text{ V}$ . The CP-Cu<sub>0.812</sub> electrode shows the highest FE of CO, 43%, at  $-0.55 \text{ V}$  and 38% FE of  $\text{CH}_4$  is achieved at  $-0.83 \text{ V}$ . The CP-Cu<sub>0.070</sub> electrodes possess mass activities of  $155$  and  $375 \text{ A mg}^{-1}$  Cu for CO and  $\text{CH}_4$ , respectively, which are 2–3 orders of magnitude higher than those reported in the literature (Table S2, ESI†). This finding indicates that Cu impurities as low as  $0.070 \mu\text{g cm}^{-2}$  (8.2 ppm relative to the total electrode) can significantly affect the performance of carbon catalysts for  $\text{C}_1$  (e.g., CO and  $\text{CH}_4$ ) generation. Our previous work found that functionalized N-doped graphene quantum dots (NGQDs) could catalyze  $\text{CO}_2$  to  $\text{CH}_4$  with a high selectivity of



Fig. 3 Product distribution of the CORR as a function of the Cu loading in the electrodes at the current density of around  $130 \text{ mA cm}^{-2}$  (a) and  $330 \text{ mA cm}^{-2}$  (b).



70% FE at  $-0.85$  V, and the Cu impurity on electrodes is  $0.056 \mu\text{g cm}^{-2}$ .<sup>32</sup> We observed that the highest FE of  $\text{CH}_4$  is 24% at  $-0.67$  V for  $0.070 \mu\text{g cm}^{-2}$  Cu and 14% at  $-0.81$  V for  $0.042 \mu\text{g cm}^{-2}$  Cu (Fig. S6, ESI†). Compared to trace Cu only, the functionalized NGQDs requires a more negative potential to reach the maximum FE of  $\text{C}_2\text{H}_4$ . The facts indicate that both functionalized NGQDs and trace Cu may contribute to  $\text{CH}_4$  formation in the  $\text{CO}_2\text{RR}$ , even though functionalized NGQDs play a more significant role.

The trace metal effect on the  $\text{CO}/\text{CO}_2\text{RR}$  can be extended to other metal impurities, such as Ag, Au, Zn, Sn, and Bi. To verify this hypothesis, we loaded trace Zn ( $\sim 1.6 \mu\text{g cm}^{-2}$ ) onto the CP by impregnating CP in a 5 mM  $\text{ZnCl}_2$  solution (2 mL,  $\text{H}_2\text{O}_{(\text{v})}/\text{IPA}_{(\text{v})} = 1/1$  solvent) for 1 h. The electrochemical activity of trace Zn to the  $\text{CO}_2\text{RR}$  is shown in Fig. S7 (ESI†). The FE of CO is higher than 60% in the wide testing potential range of  $-0.65$  to  $-1.08$  V, and the total current density reaches  $300 \text{ mA cm}^{-2}$  at  $-1.08$  V, indicating that the trace Zn on the CP exhibits outstanding activity for CO generation. M–N–C catalysts are commonly employed as single-atom metal electrocatalysts for catalyzing  $\text{CO}_2$  to CO with high FEs.<sup>41–43</sup> However, to the best of our knowledge, the metal impurities, such as Au, Ag, and Zn, were never determined and evaluated with those M–N–C catalysts, which may result in the overestimation of M–N–C catalyst performance.

### Chemical structure of Cu

In order to correlate the chemical structure and oxidation status of Cu with the electrochemical activity towards the  $\text{CORR}/\text{CO}_2\text{RR}$ , the trace Cu structure was characterized by a combination of electron microscopy and spectroscopy. The microstructure of the  $\text{CP-Cu}_{0.812}$  post-electrode was characterized by scanning electron microscopy (SEM), as shown in Fig. S8 (ESI†). No aggregate of Cu at the micron size was observed. The corresponding energy dispersive X-ray spectroscopy (EDS) elemental mapping is shown in Fig. S9 (ESI†). It is well known that characterization of ppm level Cu in carbon materials is a challenge. The Cu structure on the  $\text{CP-Cu}_{0.812}$  post-electrode was determined further with aberration-corrected scanning transmission electron microscope (AC-STEM). No metal nanoparticles or clusters were found, and only a few Cu single atoms were observed after many attempts, as shown in Fig. 4a and b.

Fig. 4c and d show the high-resolution X-ray photoelectron spectroscopy (XPS) spectra of Cu 2p of pre- and post-electrodes, respectively. No notable peaks of Cu 2p are visible on any electrodes due to the ultralow Cu loading. X-ray absorption spectroscopy (XAS) was employed to further investigate the chemical structure of Cu species at the atomic scale. Fig. 4e presents the X-ray absorption near edge structure (XANES) spectra of the Cu K-edge for  $\text{CP-Cu}_{0.070}$  (pre- and post-),  $\text{CP-Cu}_{0.333}$  (post-), and  $\text{CP-Cu}_{0.812}$  (pre- and post-) electrodes. The Cu shows a higher energy absorption edge at higher Cu loadings, suggesting an increase of Cu valence with an increase of Cu loading. The possible reason is that the high-loading Cu species are more susceptible to being oxidized by oxygen in the

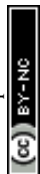
air due to the impregnation method. Compared to the pre-electrodes of  $\text{CP-Cu}_{0.812}$ , the post-electrode shows lower Cu energy due to the reduction of Cu in the  $\text{CORR}$ . The energy absorption from all electrodes is in the range between CuO and  $\text{Cu}_2\text{O}$ , indicating that Cu in the post-reaction electrodes has a chemical state of  $\text{Cu}^{\delta+}$  ( $1 < \delta < 2$ ). Fig. 4f displays the Cu Fourier-transformed  $k^3$ -weighted extended X-ray absorption fine structure (EXAFS) in  $R$  space. Only a notable peak at *ca.*  $1.5 \text{ \AA}$ , which is associated with Cu–C/O scattering, is observed in both the pre- and post-electrodes of  $\text{CP-Cu}_{0.812}$ .<sup>28,49,50</sup> No Cu–Cu bonding peak is seen for any electrodes, which confirms that the Cu species are atomically dispersed on CP. According to the analysis above, we conclude that the high electrochemical activity towards the  $\text{CO}/\text{CO}_2\text{RR}$  comes from a trace level of atomically dispersed Cu with a chemical state of  $\text{Cu}^{\delta+}$  ( $1 < \delta < 2$ ).

Since the Cu species are atomically dispersed in the CP, the TOF of trace amounts of Cu catalysts for the  $\text{CO}/\text{CO}_2\text{RR}$  were calculated assuming the existence of single atom Cu. For the  $\text{CP-Cu}_{0.333}$  electrodes, the TOF for the  $\text{CO}$ -to- $\text{C}_2$  products conversion reaches  $145 \text{ s}^{-1}$  at  $-0.86$  V, which is 4 orders of magnitude higher than those reported in the literature (Table S3, ESI†). For the  $\text{CP-Cu}_{0.042}$  electrodes, the TOF for the  $\text{CO}$ -to- $\text{CH}_4$  conversion achieves  $267 \text{ s}^{-1}$  at  $-0.87$  V, which has increased by 2 orders of magnitude compared with reported values in the literature (Table S3, ESI†).

### Proposed mechanism for the $\text{CO}/\text{CO}_2\text{RR}$ in the trace Cu loaded CPs

We attempted to propose the reaction mechanism of the  $\text{CO}/\text{CO}_2\text{RR}$  on trace Cu loaded CPs based on documented theoretical investigations and our experimental observations. At a very low Cu loading in the CP ( $< 0.333 \mu\text{g cm}^{-2}$ ), the primary product in the  $\text{CORR}$  is  $\text{CH}_4$ , while it switches to  $\text{C}_2$  when the Cu loading is higher than  $0.333 \mu\text{g cm}^{-2}$ . The predominant product switches from  $\text{C}_1$  to  $\text{C}_2$  with an increased Cu loading in the CP, while the Cu species remain atomically dispersed in the CP. The density of the Cu single atom is hypothesized to be responsible for the switch of the predominant product in the  $\text{CORR}$ . A low density of Cu loading prefers the  $\text{C}_1$  products, while a high density of Cu loading favors the  $\text{C}_2$  products. It was reported that the single-site Cu can facilitate the protonation of  $\text{CO}^*$  to  $\text{CHO}^*$  and then form  $\text{C}_1$  products due to the strong chemisorption of  $\text{H}^*$  and the high partial pressure of CO in the  $\text{CORR}$ .<sup>28</sup> The lack of Cu pair active sites makes  $\text{C}_1$  the primary product. The C–C coupling is accelerated with the increase of atomic Cu density.<sup>27</sup> The C–C coupling reaction can proceed *via* either the Eley–Rideal mechanism or the Langmuir–Hinshelwood mechanism. The Eley–Rideal mechanism is supposed to be predominant in the  $\text{CORR}$  due to the high partial pressure of CO.

Distinguished from the  $\text{CORR}$ , the main product is only  $\text{C}_1$  (*e.g.*, CO and  $\text{CH}_4$ ) in the  $\text{CO}_2\text{RR}$  with trace amounts of Cu, indicating that the C–C coupling in the  $\text{CO}_2\text{RR}$  is more challenging than that in the  $\text{CORR}$ . One possible reason is that it is difficult for the C–C coupling to occur by the Eley–Rideal mechanism due to the low pressure of CO under the  $\text{CO}_2\text{RR}$  conditions. The other



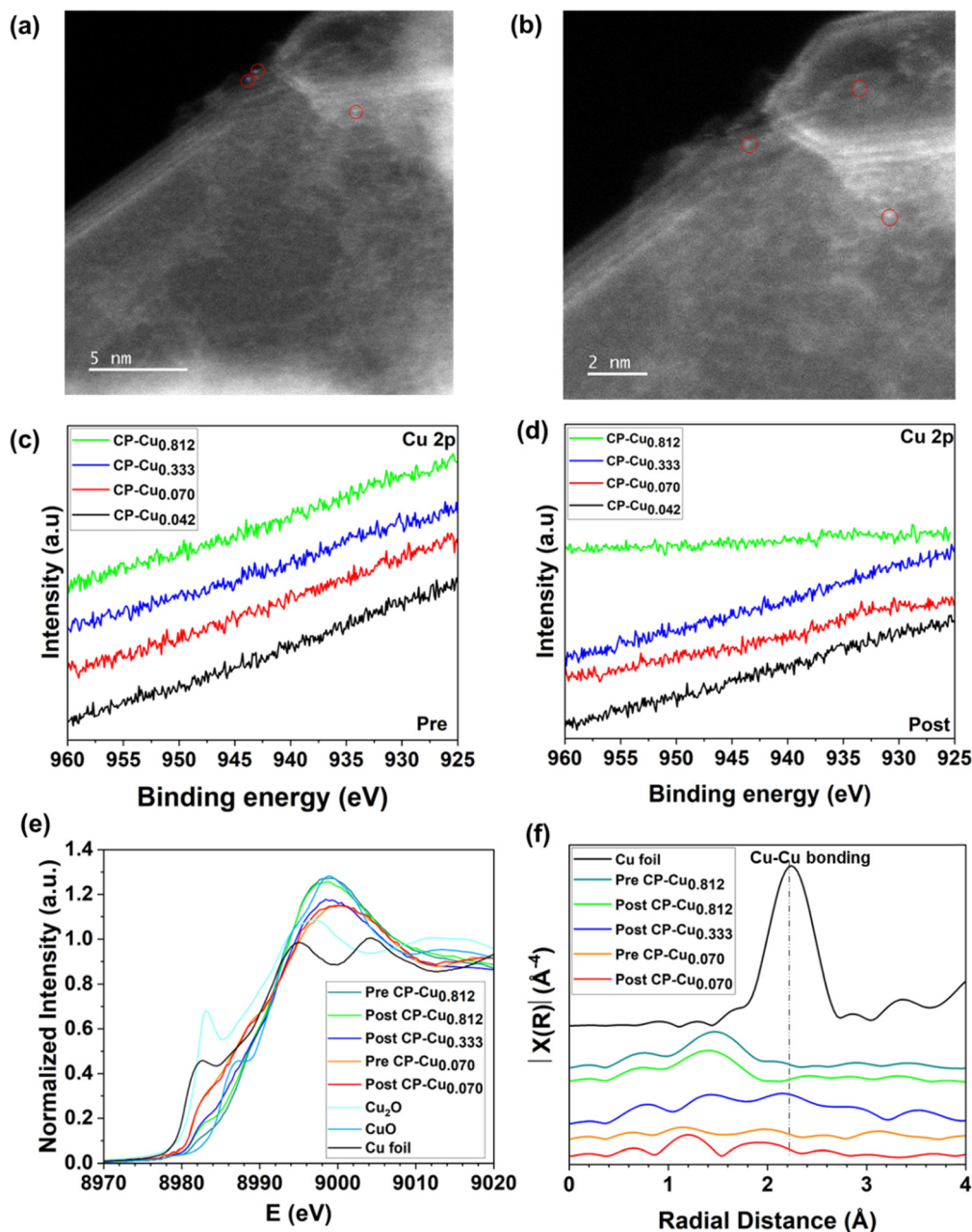


Fig. 4 Structural characterization of the CP-Cu electrodes. (a and b) AC-HAADF-STEM images of single atom Cu in the CP-Cu<sub>0.812</sub> post-electrode after the CORR. (c) High-resolution XPS spectra of Cu 2p of the pre-experiment CP-Cu electrodes. (d) High-resolution XPS spectra of Cu 2p of the post-experiment CP-Cu electrodes in the CORR. (e) Cu K-edge normalized XANES spectra as a function of incident photon energy ( $E$ ) for the CP-Cu electrodes. (f) Fourier transform of  $k^3$ -weighted EXAFS in  $R$  space of the CP-Cu electrodes.

possible reason is that the CO<sub>2</sub> is more inert than CO, and the adoption of CO<sub>2</sub> on the Cu species is much more difficult than for CO.

## Conclusions

We revealed the activity and selectivity of trace amounts of Cu with various loadings towards the CO/CO<sub>2</sub>RR by simply impregnating Cu onto CP. An extraordinary mass specific activity and

selectivity toward the CORR is observed with 50% FE of carbon products including the predominant CH<sub>4</sub> when the Cu loading is higher than 0.042  $\mu\text{g cm}^{-2}$ . The predominant product switches from CH<sub>4</sub> to C<sub>2</sub> with an increase of Cu to 0.333  $\mu\text{g cm}^{-2}$ . When further increasing the Cu loading to 0.812  $\mu\text{g cm}^{-2}$ , the overall highest FE of C<sub>2</sub> achieves 78%, of which the major product of CH<sub>3</sub>COO<sup>-</sup> accounts for 42%. The record mass activities for CH<sub>4</sub> and C<sub>2</sub> reach 2435 and 584 A mg<sup>-1</sup> of Cu, corresponding to TOFs of 267 and 145 s<sup>-1</sup>, respectively. Different from the CORR, a higher loading of Cu is required to trigger the CO<sub>2</sub>RR. Moreover, trace



Cu primarily catalyzes the CO<sub>2</sub>RR to form C<sub>1</sub> (e.g., CO and CH<sub>4</sub>) even when the Cu loading reaches 0.812 μg cm<sup>-2</sup>, indicating trace Cu is not in favor of C–C coupling in the CO<sub>2</sub>RR. The effect of trace metal impurities can be extended to others that are active towards the CO<sub>2</sub>RR, such as Zn for CO<sub>2</sub>-to-CO conversion. We suggest that the effect of trace metal impurities must be quantified when developing metal-free and M–N–C catalysts for the CO/CO<sub>2</sub>RR.

## Disclaimer

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## Conflicts of interest

There are no conflicts to declare.

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